

Fundamental methods of single-crystal growth

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Single-crystal and its growth

- Single-crystal
 - regular arrangement of basic building blocks (atoms, ions, molecules) is preserved on the macroscopic scale → structure anisotropy is mirrored in the physical property anisotropy
- Single-crystal growth
 - solid phase must be created under the physical conditions close to the thermodynamic equilibrium (stacking „atom-by-atom“ on the seed crystal surface)

Methods of single-crystal growth

Classification by Wilke:

- 1) From the dispersion phase (solutions, gases,...)
- 2) From the own melt
- 3) From the solid phase

Single-crystal growth from the dispersion phase

- From the gas phase
 - sublimation
 - chemical reaction (e.g. “hot wire” method)
- From the (low temperature) solutions
 - evaporation (isothermal)
 - cooling (speed growth)
 - gradient method
 - chemical reaction
- Hydrothermal
- From the melt solutions (flux)

Single-crystal growth from the own melt

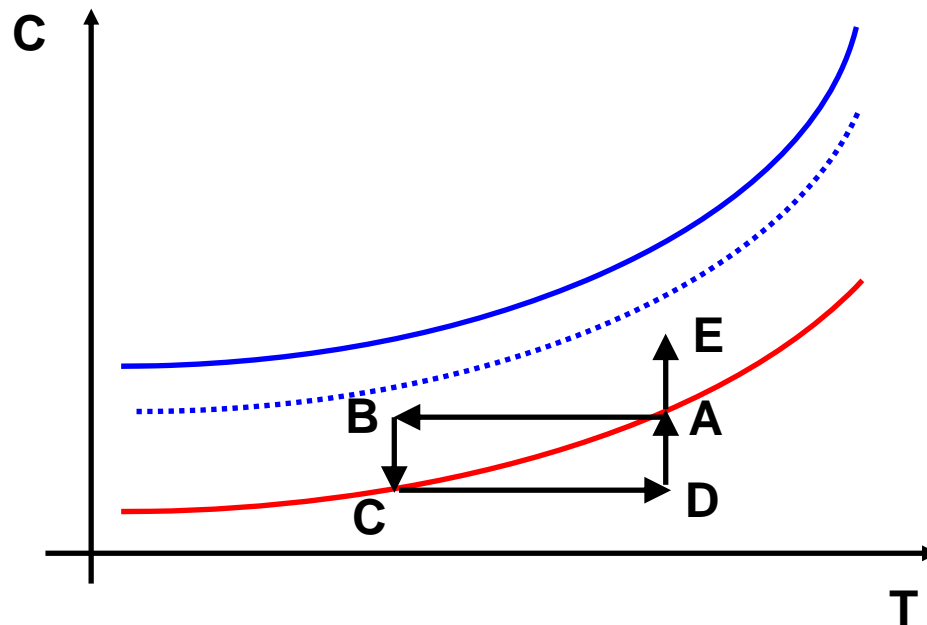
- **Crucible methods**
 - stationary crucible methods
 - Czochralski method
 - Bridgman-Stockbarger method
 - Stěpanov method (EFG)
 - zonal melting
- **Methods without crucible**
 - Verneuil method
 - „cool crucible“ method

Single-crystal growth from the solid phase

- Recrystallization
 - mechanical
 - by annealing

Low temperature solutions

- materials solvable at room temperature in suitable solvent (water, ethanol, acetone, ...), e.g. TGS ($(\text{NH}_2\text{CH}_2\text{COOH})_3 \cdot \text{H}_2\text{SO}_4$), KDP (KH_2PO_4), ADP ($\text{NH}_4\text{H}_2\text{PO}_4$), ...



- Solubility curve
- Curve of mass crystallization
- ⋯ Boundary of unstable range

oversaturation $\sigma = \frac{\Delta c}{c} \cdot 100[\%]$

solubility ratio $\alpha = \frac{dc}{dT}$

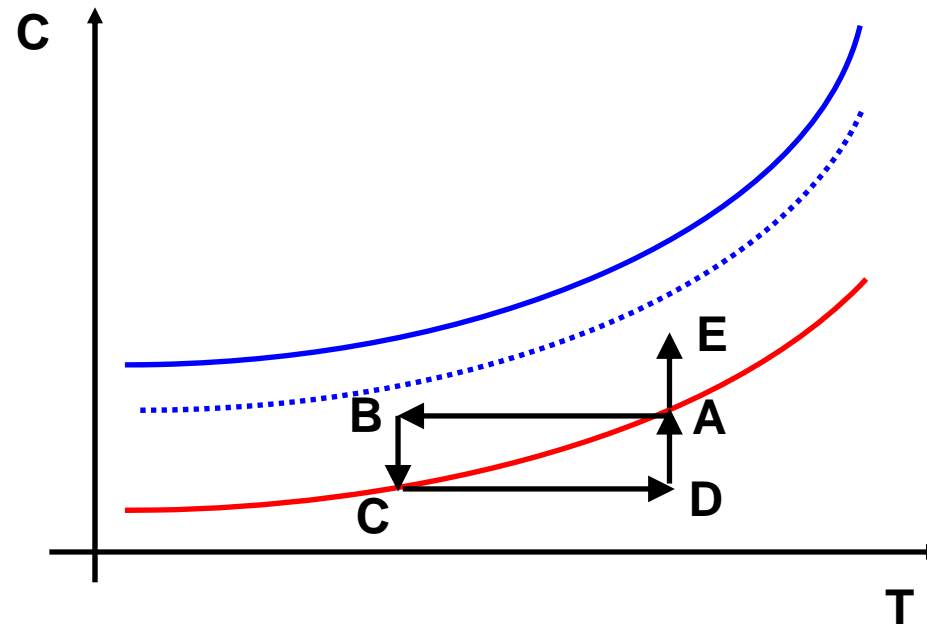
for the most materials $\alpha > 0$

$T \in (15^\circ\text{C} - 60^\circ\text{C})$

Low temperature solutions

Principles of methods:

- AE – evaporation
- AB – cooling
- ABCD – gradient method



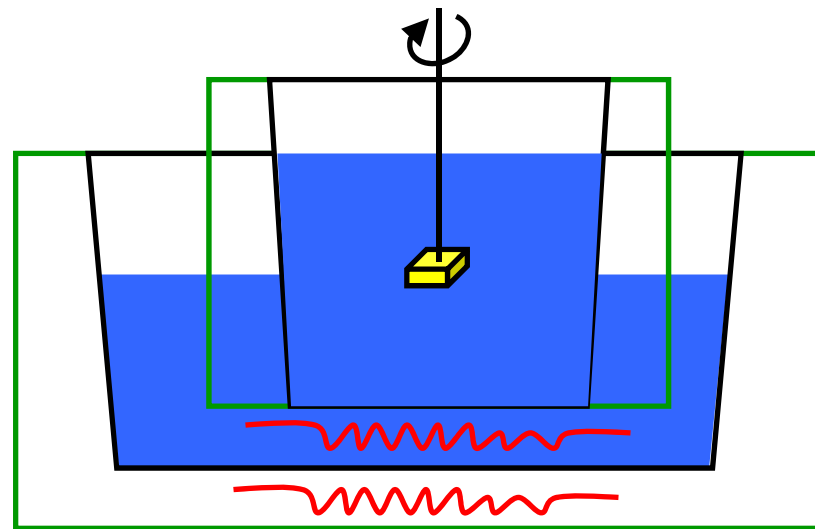
Evaporation

- Advantages
 - simple isothermal method
 - independent from α
- Drawback
 - difficult control of evaporation speed \rightarrow growth fluctuation \rightarrow defects and parasitic crystal occur

Suitable method for the easy tentative laboratory single-crystal growth (e.g. $\text{CuSO}_4 \cdot 5(\text{H}_2\text{O})$).

Cooling

- highly demanding temperature stability, fluctuation $<0,01\text{K}$
- typical temperature changes $\approx 0,1\text{--}1\text{K/day}$
- slow crystal growth (approx. $0,5\text{mm/day}$)
- quality crystals



Speed crystal growth

- “cooling” method variant
- process is closer to the unstable boundary range
- measurement of crystal growth and feedback for the growth parameters
- growth speed approx. 50mm/day
- large and quality crystals

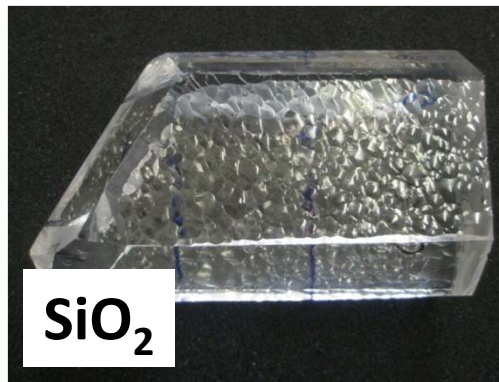
Gradient method

- two-stage or three-stage crystallizer
- solution saturation (high temperature) and crystal growth at different places, necessary to filter the solution
- large and quality crystals
- expensive technology



Hydrothermal growth

- similar principle like for the low temperature solutions
- solubility is increased by the high pressure and temperature (autoclave)
- crystallization by cooling
- suitable for single-crystal growth of SiO_2 , ZnO , ...



Solutions of melts (flux)

- applicable also for the materials melted non-congruently
- usually smaller crystals with defects (inclusions of flux particles)
- problem is the proper flux choice (e.g. PbO , Bi_2O_3 , B_2O_3 , PbF)
- grown single-crystal separation problems
- modifications of the growth from the own melt (especially Schmidt-Viechnicki and Bridgman-Stockbarger method) are growing methods
- material examples:
 - YIG ($\text{Y}_3\text{Fe}_5\text{O}_{12}$)
 - PZN-PT ($\text{Pb}(\text{Zn}_{1/3}\text{Nb}_{2/3})\text{O}_3 - \text{PbTiO}_3$)
 - PMN-PT ($\text{Pb}(\text{Mg}_{1/3}\text{Nb}_{2/3})\text{O}_3 - \text{PbTiO}_3$)

Growth from the own melt

- General conditions
 - congruent melting of the material
 - technically achievable melting temperature
- Heating methods
 - resistive
 - inductive

Crucible methods

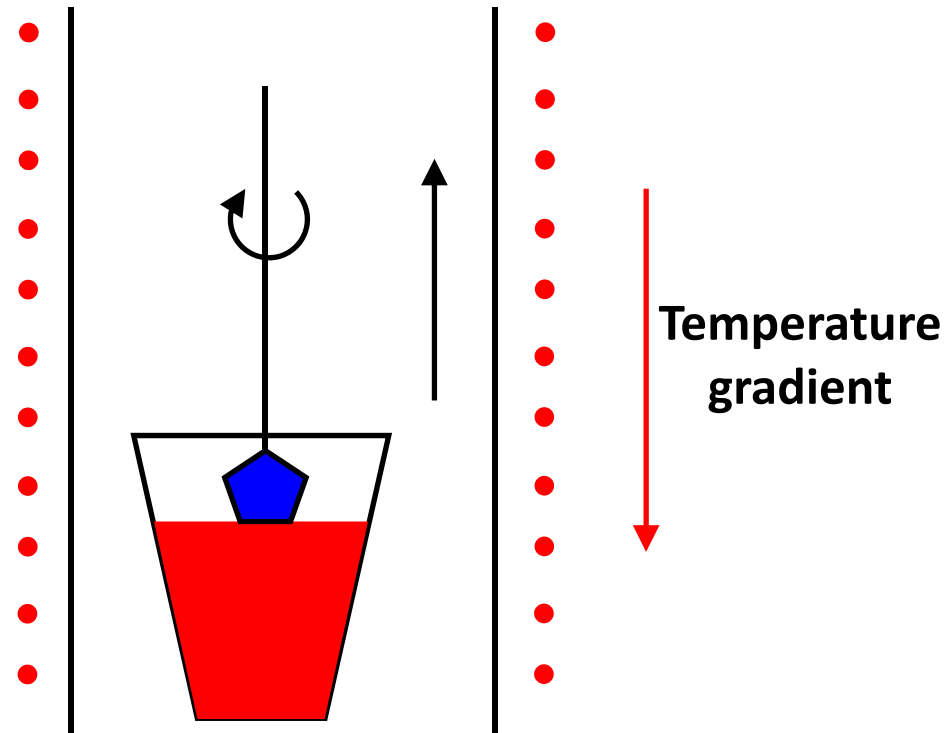
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Stationary crucible methods

- Nacken-Kyropoulos method
 - stationary growth in the crucible
 - seed crystal on the surface with the possibility of its rotation
 - heat outlet by the seed bar
 - melt cooling
- Schmidt-Viechnicki method
 - stationary growth in the crucible
 - seed crystal at the crucible bottom
 - melt cooling

Czochralski method

- temperature field gradient
- pulling of growing single-crystal



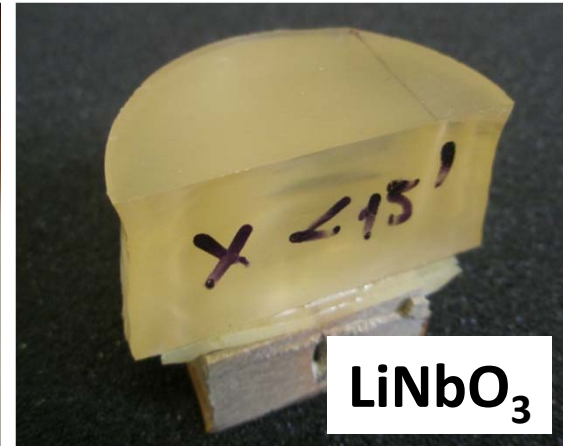
Czochralski method – materials

- material examples:
 - YAG ($\text{Y}_3\text{Al}_5\text{O}_{12}$) with dopants, e.g. YAG:Nd, YAG:Ce
 - YAP (YAlO_3) with dopants, e.g. YAP:Nd, YAP:Ce
 - LN (LiNbO_3)
 - BGO white ($\text{Bi}_4\text{Ge}_3\text{O}_{12}$)
 - BGO brown ($\text{Bi}_{12}\text{GeO}_{20}$)
 - PGO ($\text{Pb}_5\text{Ge}_3\text{O}_{11}$)
 - Al_2O_3 with dopants, e.g. Al_2O_3 :Cr (ruby), Al_2O_3 :Ti
 - PbWO_4

Czochralski method – materials



PGO



LiNbO₃



PbWO₄



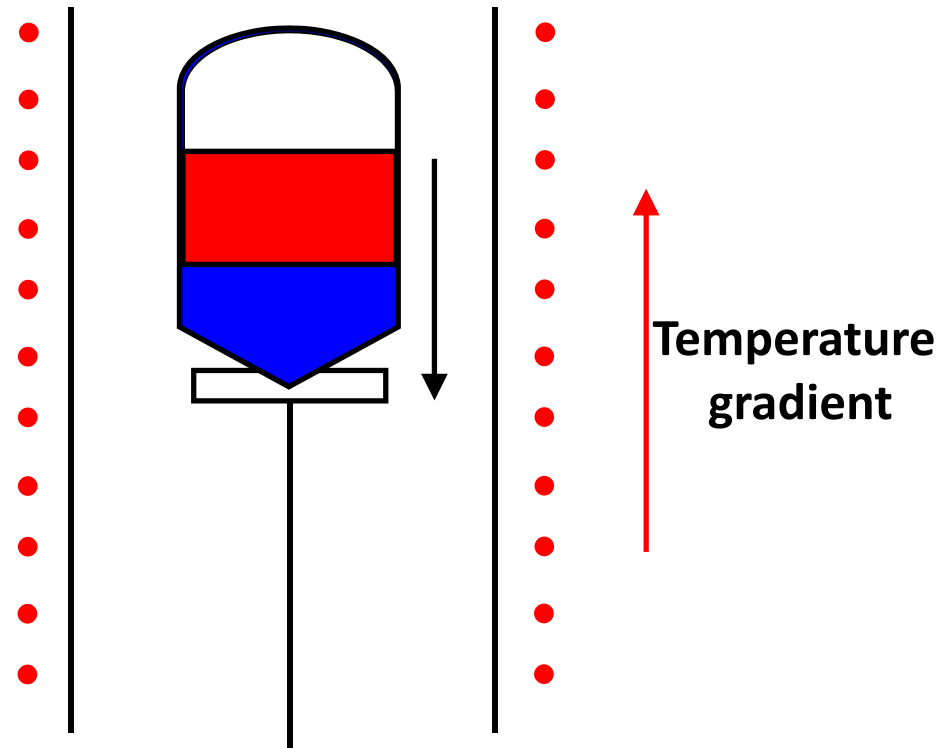
Rubín



YAP

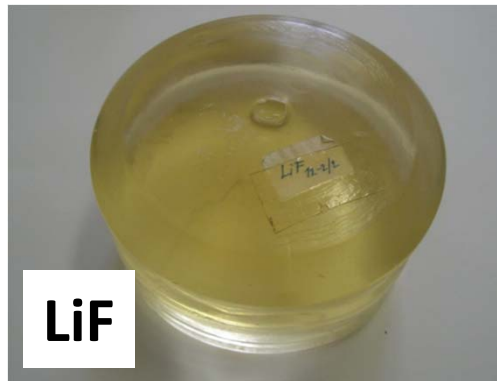
Bridgman-Stockbarger method

- temperature field gradient
- descent of the crucible with growing single-crystal



Bridgman-Stockbarger method – materials

- material examples:
 - BGO white ($\text{Bi}_4\text{Ge}_3\text{O}_{12}$)
 - CaF_2
 - CeF_3
 - NaI:Tl
 - LiF



Comparison of mostly used crucible methods

- Czochralski method
 - growth of the best quality crystals from the own melt
 - melt may not be volatile
 - atmosphere problems
- Bridgman-Stockbarger method
 - Crucible could be hermetically sealed
 - Multiple growth possible

Both methods have many variants (different types of heating, atmosphere, crucible material etc.).

Stěpanov method (EFG)

- growth of profile single-crystals
- pulling the seed crystal without rotation through the dies
- necessary condition – melt capillarity on the dies material surface

Profile single-crystals of Al_2O_3 are mostly grown by this method.

Zonal melting

Method principle:

- horizontal pulling of sintered (polycrystalline) material in the crucible of elongated shape (boat) through the zone with the temperature above melting point → recrystallization (macroscopic single-crystal growth at the optimum conditions) and refining of the material

Method is mostly applied for the single-crystal growth of semiconductor materials (Si, Ge).



Growth methods without crucible

- Verneuil method
- “cool crucible” method

Growth methods without crucible are suitable for the materials with the high melting temperature.

Verneuil method

Method principle:

- melting of the powder material in the flame and melt droplets deposition onto the surface of crystal inside the temperate chamber
- Drawbacks
 - growth conditions are far from the thermodynamic equilibrium
 - structural defects occur
- Advantage
 - high concentration of dopants possible
- Material examples:
 - Al_2O_3 with different dopants



„Cool crucible“

Method principle:

- inductive heating, conductive melt × non-conductive solid, starting conductive material, cooled inductor keeps the crust of melted material
- Drawback
 - generation of larger quantity of smaller single-crystals
- Material examples:
 - ZrO_2